

This listing of claims will replace prior versions, and listings, of claims in the application:

Listing Of Claims:

Claims 2, 4, 8, 9, 16, 21, 22, and 24 (Canceled)

1 1. (Currently Amended) Apparatus for automatically measuring the surface
2 properties of optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a predetermined wavefront
5 profile;
6 means for controllably ~~positioning~~translating said output beam along an optic
7 axis with respect to said support so that said predetermined wavefront profile thereof
8 impinges on said element from a predetermined direction and then is reflected to
9 travel opposite said predetermined direction as a distorted wavefront containing
10 distortions that vary in accordance with the topography of said test surface and the
11 position of said output beam along said optic axis; ~~and~~
12 means for sampling said distorted wavefront profile at predetermined locations
13 thereover as said output beam is ~~moved~~translated relative to said test surface and
14 determining the local deformation of said wavefront everywhere corresponding to a
15 sampled location on said test surface and the position of said output beam with
16 respect to said test surface along said optical axis; ~~and~~
17 analytical means for representing the topography of said test surface with a
18 mathematical approximation comprising a series of coefficients and variables;
19 calculating the value of said coefficients based on the local deformation of said
20 wavefront at a plurality of positions of said source with respect to said test surface,
21 said coefficients being polynomial of at least second order.

3. (Currently Amended) The apparatus of claim [2]-1 wherein said analytical means includes means for performing an optimization analysis using the values of said coefficients calculated for each position of said source and test surface to arrive at a final value for said coefficients that are used for said mathematical approximation to represent the shape of said surface to a predetermined accuracy.

5. (Original) The apparatus of claim 1 wherein said predetermined wavefront comprises a nominally spherical wavefront.

6. (Original) The apparatus of claim 1 wherein said means for generating said output beam comprises a light source and collimating optics.

7. (Original) The apparatus of claim 6 further including a well-corrected objective lens.

10. (Currently Amended) The apparatus of claim [9]-26 further including a relay section.

11. (Currently Amended) The apparatus of claim [4]-26 further including a beam expansion section.

12. (Original) The apparatus of claim 1 wherein said means for sampling said distorted wavefront comprises a two-dimensional lens array and a two-dimensional photodetector array having discrete sensing elements.

13. (Original) The apparatus of claim 12 wherein said two-dimensional lens array comprises a pair of crossed lenticular screens with index mismatching material between them.

14. (Currently Amended) The apparatus of claim [~~12~~]-1 wherein said means for generating said output beam comprises a microscope objective lens and further including a telescopic section between said microscope objective lens and said two-dimensional lens array to image said two-dimensional photodetector array into the pupil of said microscope objective lens.

1 15. (Currently Amended) Apparatus for automatically measuring the
2 properties of surfaces that are at least partially specularly reflective, said apparatus
3 comprising:
4 a support for an element having at least one test surface to be measured;
5 a source having an output with a predetermined wavefront profile;
6 means for controllably ~~moving~~translating said source and said support
7 relative to one another along an optic axis so that a test surface in said support
8 continuously reflects said output from said source back towards said source while
9 distorting said wavefront profile thereof in accordance with the topography of said test
10 surface and the relative position of said source with respect to said test surface along
11 said optic axis; and
12 means for sampling said distorted wavefront profile at predetermined locations
13 thereover as said source is ~~moved~~translated relative to said test surface along said
14 optical axis and determining the local deformation of said wavefront everywhere
15 corresponding to a sampled location and the position of said source with respect to
16 said test surface along said optical axis; and
17 analytical means for representing the topography of said test surface with a
18 mathematical approximation comprising a series of coefficients and variables;
19 calculating the value of said coefficients based on the local deformation of said
20 wavefront at at least one position of said source with respect to said test surface
21 wherein said coefficients are polynomial of at least second order.

17. (Original) The apparatus of claim 15 wherein said analytical means includes means for performing an optimization analysis using the values of said coefficients calculated for each position of said source and test surface to arrive at a final value for said coefficients that are used for said mathematical approximation to represent the shape of said surface to a predetermined accuracy.

18. (Original) The apparatus of claim 1 wherein said means for sampling said distorted wavefront profile comprises a two-dimensional lenslet array having a focal plane and a one-dimensional photodetector array arranged to scan across said focal plane.

19. (Original) The apparatus of claim 1 wherein said means for generating an output beam comprises one of a pulsed light source or strobe.

1 20. (Currently Amended) A method for automatically measuring the surface
2 properties of optical elements, said method comprising the steps of:
3 supporting an element having at least one test surface to be measured;
4 generating an output beam having a predetermined wavefront profile;
5 controllably positioning said output beam with respect to said support so that
6 said predetermined wavefront profile thereof impinges on said element from a
7 predetermined direction and then is reflected to travel opposite said predetermined
8 direction as a distorted wavefront containing distortions that vary in accordance with
9 the topography of said test surface and the position of said output beam; and
10 sampling said distorted wavefront profile at predetermined locations thereover
11 as said output beam is moved relative to said test surface and determining the local
12 deformation of said wavefront everywhere corresponding to a sampled location and
13 the position of said output beam with respect to said test surface; and
14 analytically representing the topography of said test surface with a
15 mathematical approximation comprising a series of coefficients and variables and
16 calculating the value of said coefficients based on the local deformation of said
17 wavefront at at least one position of said source with respect to said test surface
18 wherein said coefficients are polynomial of at least second order.

23. (Currently Amended) The method of claim [22]-20 further including the step of determining the shape factor of an aspheric surface.

25. (Currently Amended) The method of claim [24]-31 further including the step of determining any offset between a programmed lathe tool and the axis of the lathe.

1 --26. (New) Apparatus for automatically measuring the surface properties of
2 optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a plane wavefront profile;

5 means for controllably translating said output beam along an optic axis with
6 respect to said support so that said predetermined wavefront profile thereof impinges
7 on said element from a predetermined direction and then is reflected to travel
8 opposite said predetermined direction as a distorted wavefront containing distortions
9 that vary in accordance with the topography of said test surface and the position of
10 said output beam along said optic axis;
11 means for sampling said distorted wavefront profile at predetermined locations
12 thereover as said output beam is translated relative to said test surface and
13 determining the local deformation of said wavefront everywhere corresponding to a
14 sampled location on said test surface and the position of said output beam with
15 respect to said test surface along said optical axis; and
16 a reflective means positioned with respect to said support to facilitate the
17 measurement of transmitted wavefront errors in optical bandpass components
18 including filters and windows.--

1 --27. (New) Apparatus for automatically measuring the surface properties of
2 optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a predetermined wavefront
5 profile;
6 means for controllably translating said output beam along an optic axis with
7 respect to said support so that said predetermined wavefront profile thereof impinges
8 on said element from a predetermined direction and then is reflected to travel
9 opposite said predetermined direction as a distorted wavefront containing distortions
10 that vary in accordance with the topography of said test surface and the position of
11 said output beam along said optic axis;
12 means for sampling said distorted wavefront profile at predetermined locations
13 thereover as said output beam is translated relative to said test surface and
14 determining the local deformation of said wavefront everywhere corresponding to a
15 sampled location on said test surface and the position of said output beam with
16 respect to said test surface along said optical axis; and

17 a positive lens located in a fixed position with respect to said support and
18 along said predetermined direction to facilitate the measurement of parts having long
19 radii of curvature.--

1 --28. (New) Apparatus for automatically measuring the surface properties of
2 optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a plane wavefront profile;
5 means for controllably translating said output beam along an optic axis with
6 respect to said support so that said predetermined wavefront profile thereof impinges
7 on said element from a predetermined direction and then is reflected to travel
8 opposite said predetermined direction as a distorted wavefront containing distortions
9 that vary in accordance with the topography of said test surface and the position of
10 said output beam along said optic axis; and
11 means for sampling said distorted wavefront profile at predetermined locations
12 thereover as said output beam is translated relative to said test surface and
13 determining the local deformation of said wavefront everywhere corresponding to a
14 sampled location on said test surface and the position of said output beam with
15 respect to said test surface along said optical axis and wherein said means for
16 sampling said distorted wavefront comprises a two-dimensional lens array and a two-
17 dimensional photodetector array having discrete sensing elements and wherein said
18 two-dimensional lens array comprises a pair of crossed lenticular screens with index
19 mismatching material between them.--

1 --29. (New) Apparatus for automatically measuring the surface properties of
2 optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a predetermined wavefront
5 profile;
6 means for controllably translating said output beam along an optic axis with
7 respect to said support so that said predetermined wavefront profile thereof impinges
8 on said element from a predetermined direction and then is reflected to travel
9 opposite said predetermined direction as a distorted wavefront containing distortions

10 that vary in accordance with the topography of said test surface and the position of
11 said output beam along said optic axis;
12 means for sampling said distorted wavefront profile at predetermined locations
13 thereover as said output beam is translated relative to said test surface and
14 determining the local deformation of said wavefront everywhere corresponding to a
15 sampled location on said test surface and the position of said output beam with
16 respect to said test surface along said optical axis and wherein said means for
17 sampling said distorted wavefront profile comprises a two-dimensional lenslet array
18 having a focal plane and a one-dimensional photodetector array arranged to scan
19 across said focal plane.--

1 --30. (New) Apparatus for automatically measuring the surface properties of
2 optical elements, said apparatus comprising:
3 a support for an element having at least one test surface to be measured;
4 means for generating an output beam having a predetermined wavefront
5 profile, said means for generating an output beam comprises one of a pulsed light
6 source or strobe;
7 means for controllably translating said output beam along an optic axis with
8 respect to said support so that said predetermined wavefront profile thereof impinges
9 on said element from a predetermined direction and then is reflected to travel
10 opposite said predetermined direction as a distorted wavefront containing distortions
11 that vary in accordance with the topography of said test surface and the position of
12 said output beam along said optic axis; and
13 means for sampling said distorted wavefront profile at predetermined locations
14 thereover as said output beam is translated relative to said test surface and
15 determining the local deformation of said wavefront everywhere corresponding to a
16 sampled location on said test surface and the position of said output beam with
17 respect to said test surface along said optical axis.--

1 --31. (New) A method for automatically measuring the surface properties of
2 optical elements, said method comprising the steps of:
3 supporting an element having at least one test surface to be measured;
4 generating an output beam having a predetermined wavefront profile;

5 controllably positioning said output beam with respect to said support so that
6 said predetermined wavefront profile thereof impinges on said element from a
7 predetermined direction and then is reflected to travel opposite said predetermined
8 direction as a distorted wavefront containing distortions that vary in accordance with
9 the topography of said test surface and the position of said output beam; and
10 sampling said distorted wavefront profile at predetermined locations thereover
11 as said output beam is moved relative to said test surface and determining the local
12 deformation of said wavefront everywhere corresponding to a sampled location and
13 the position of said output beam with respect to said test surface; and
14 analytically representing the topography of said test surface with a
15 mathematical approximation comprising a series of coefficients and variables and
16 calculating the value of said coefficients based on the local deformation of said
17 wavefront at at least one position of said source with respect to said test surface
18 wherein said coefficients are polynomial of at least second order, and
19 determining the offset between axis of the surface being measured and that of
20 the apparatus used to measure it.--